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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/663,698	09/17/2003	Chung-Hee Chang	50103-527	3980	
7	09/17/2003 Chung-Hee Chang 7590 05/18/2005 OTT, WILL & EMERY reet, N.W.	EXAMINER			
MCDERMOTT, WILL & EMERY 600 13th Street, N.W. Washington, DC 20005-3096			CHEN, BRET P		
			ART UNIT	PAPER NUMBER	
0 /			1762	<del></del>	

DATE MAILED: 05/18/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	
	10/663,698	CHANG ET AL.	
Office Action Summary	Examiner	Art Unit	
•	B. Chen	1762	
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet wit	h the correspondence a	ddress
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period v - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a re y within the statutory minimum of thirty will apply and will expire SIX (6) MONT , cause the application to become ABA	ply be timely filed (30) days will be considered time THS from the mailing date of this NDONED (35 U.S.C. § 133).	
Status			
<ul> <li>1) ⊠ Responsive to communication(s) filed on 25 Fe</li> <li>2a) ☐ This action is FINAL. 2b) ⊠ This</li> <li>3) ☐ Since this application is in condition for alloware closed in accordance with the practice under E</li> </ul>	action is non-final. nce except for formal matte	<del>-</del>	e merits is
Disposition of Claims			
<ul> <li>4)</li></ul>	s/are withdrawn from consi	deration.	
Application Papers			
9) The specification is objected to by the Examine			
	epted or b) objected to b	•	
Applicant may not request that any objection to the	***	· ·	)FD 4 404(4)
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	, ,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,		` '
Priority under 35 U.S.C. § 119			
12) ☐ Acknowledgment is made of a claim for foreign	ndodty under 25 LLS C. S.	110(a) (d) ar (f)	
a) Acknowledgment is made of a daily for foreign  a) All b) Some * c) None of:  1. Certified copies of the priority document  2. Certified copies of the priority document  3. Copies of the certified copies of the priority document  application from the International Bureau	s have been received. s have been received in Aprity documents have been	oplication No	I Stage
* See the attached detailed Office action for a list	, , , , , , , , , , , , , , , , , , , ,	received.	
Attachment(s)			
<ol> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date</li> </ol>	Paper No(s)	ummary (PTO-413) VMail Date formal Patent Application (PT _·	O-152)

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## **DETAILED ACTION**

Claims 1-25 are pending in this application.

## Election/Restrictions

Applicant's election of claims 1-11, 13-15, 17, 19, 21, 23-25 in the reply filed on 2/25/05 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-11, 13-15, 17, 19, 21, 23-25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Mizunoya et al. (5,731,068). Mizunoya discloses a method of forming a magnetic recording medium having improved recording density which comprises depositing multilayer magnetic layers formed on a magnetic recording medium

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(col.1 lines 5-7 and col.2 lines 28-34). Specifically, a magnetic layer comprising a multilayer structure (3,4) is formed on the support (2) followed by a protective layer (6) (col.2 lines 45-54 and col.3 lines 53-60). During vapor deposition, an oxidizing gas, e.g., oxygen gas, is introduced through each of oxidizing gas introducing pipes 26 and 27 to regulate each vapor-deposited metal film to improve coercive force and C/N characteristics (col.9 lines 15-42). In addition, a continuous substrate can be processed in a deposition apparatus (Figure 3) under sub-atmospheric pressure (col.7 lines 53-58). However, the reference remains silent as to either a) a more negative nucleation field, b) increased remanent squareness, c) increased SMNR, d) narrower SFD, or e) decreased thermal decay rate.

It is noted that the reference clearly teaches of using an oxidizing gas to improve coercive force and C/N characteristics as noted above although it remains silent on the benefits noted by the applicant. The mere observation of still another beneficial result of an old process cannot form the basis of patentability.

In addition, the reference fails to teach different portions of the apparatus. It is noted that the reference clearly teaches of depositing different coatings in different parts of the coating apparatus as noted above. One skilled in the art would realize that it would be cheaper to combine areas of an apparatus for coating when appropriate. It would have been obvious to the skilled artisan to combine the second and third portions with the expectation of obtaining a more efficient deposition process and in the absence of a showing of criticality.

The limitations of 2-11, 13-15, 17, 19, 21, 23-25 have been addressed above.

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Yamada et al. (6,153,063), Chiba et al. (5,925,404), and Ueda et al. (5,677,051)

have been cited as relevant art.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to B. Chen whose telephone number is (571) 272-1417. The examiner can normally be reached on 7:30am - 4:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Bc 5/13/05

BRET CHEN
PRIMARY EXAMINER